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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Robert Bertram Ogle, Jr. and Arvind Halliyal

Assignee: Advanced Micro Devices, Inc.

Title: Process For Treating ONO Dielectric Film Of A Floating Gate Memory Cell

Serial No.: 09/927,134 Filing Date: August 10, 2001

Examiner: Weiss, H. Group Art Unit: 2814

Docket No.: M-7525 US Client Ref.: D897

San Jose, California
August 5, 2002

COMMISSIONER FOR PATENTS
Washington, D. C. 20231

PETITION FOR EXTENSION OF TIME

Dear Sir:

Applicants respectfully petition for a 1-month extension of time within which to respond to the April 10, 2002 outstanding Office Action, such extension allowing the undersigned until August 10, 2002 to respond.

Please charge the amount of \$110.00 as set forth in the enclosed transmittal letter.

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Respectfully submitted,

Norman R. Klivans

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Attorney for Applicants
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